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High-Power Lasers and Applications VI

Upendra N. Singh
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Editors

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Contents

vii	<i>Symposium Committees</i>
ix	<i>Conference Committee</i>
xi	<i>Quantum dot lasers and relevant nanoheterostructures (Plenary Paper) [8552-1]</i> <i>A. E. Zhukov, N. V. Kryzhanovskaya, A. V. Savelyev, A. M. Nadtochiy, E. M. Arakcheeva, F. I. Zubov, V. V. Korenev, Saint Petersburg Academic Univ. (Russian Federation); M. V. Maximov, Y. M. Shernyakov, M. M. Kulagina, I. A. Slovinskiy, Ioffe Physical-Technical Institute (Russian Federation); D. A. Livshits, Innolume GmbH (Germany); A. Kapsalis, C. Mesaritis, D. Syvridis, Univ. of Athens (Greece); A. Mintairov, Univ. of Notre Dame (United States)</i>

HIGH POWER LASERS

8551 02	Theoretical and experimental investigation of Rb-Ar excimer pumped alkali laser characteristics [8551-2] D. Yue, W. Li, H. Wang, Z. Yang, X. Xu, National Univ. of Defense Technology (China)
8551 03	Gas dynamic effect in high energy fluid diode pumped alkali vapor laser [8551-3] Y. Xu, W. Li, H. Wang, Z. Yang, X. Xu, National Univ. of Defense Technology (China)
8551 04	Competition between spontaneous radiation and ionization in the process of resonance enhanced multi-photon ionization [8551-4] G. Zhang, H. Li, H. Zheng, H. Ji, North China Electric Power Univ. (China)

SLAB LASERS I

8551 05	Variation of thermal lens curvature type between the convex and the concave lens for zigzag slab laser [8551-5] X. Fu, Q. Liu, M. Gong, Tsinghua Univ. (China)
8551 06	Nonlinear imaging properties of two parallel gain-typed wirelike scatterers [8551-7] J. Huang, Y. Hu, Hunan Univ. of Science and Technology (China)
8551 07	In-situ measurement based on prior calibration with analogist samples for laser cladding [8551-8] J. Liu, Y. Wu, L. Wang, Hunan Univ. (China)
8551 08	Temperature and align effects on efficiency of cholesteric liquid crystal based laser [8551-9] F. Wang, Y. Liu, X. Liu, W. Sun, Harbin Engineering Univ. (China)
8551 09	Evaluation method of thermal recovery uniformity for high energy amplifier [8551-10] Z. Ren, J. Zhu, Shanghai Institute of Optics and Fine Mechanics (China)

FIBER LASERS

- 8551 0A **Ultra-fast ytterbium fiber laser operating at low repetition rate (Invited Paper)** [8551-11]
J.-B. Lecourt, S. Boivinet, Y. Hernandez, Multitel ASBL (Belgium)
- 8551 0B **Single-mode linearly polarized high power fiber laser at 1120 nm** [8551-12]
J. Wang, Shanghai Institute of Optics and Fine Mechanics (China) and National Univ. of Defense Technology (China); J. Hu, L. Zhang, Shanghai Institute of Optics and Fine Mechanics (China); J. Chen, National Univ. of Defense Technology (China); Y. Feng, Shanghai Institute of Optics and Fine Mechanics (China)
- 8551 0E **Femtosecond fiber lasers for biomedical solutions** [8551-15]
J. Liu, L. Yang, PolarOnyx, Inc. (United States)

SLAB LASERS II

- 8551 0G **Design and modeling of 10-kW level single-side-pumped slab laser amplifier chain** [8551-17]
X. Fu, M. Gong, Tsinghua Univ. (China)

ULTRAFAST LASERS

- 8551 0M **Mode-locking characteristics of all-solid-state mode-locked laser with graphene saturable absorber** [8551-26]
J. Wang, L. Wang, Beijing Univ. of Technology (China)
- 8551 0P **Coherent beam combination of seven high power fiber amplifiers with an all-optical feedback loop** [8551-30]
H. Liu, Shanghai Institute of Optics and Fine Mechanics (China) and Graduate Univ. of the Chinese Academy of Sciences (China); B. He, J. Zhou, C. Liu, Shanghai Institute of Optics and Fine Mechanics (China); L. Hao, S. Dai, Shanghai Institute of Optics and Fine Mechanics (China) and Graduate Univ. of the Chinese Academy of Sciences (China); Y. Qi, X. Chen, Shanghai Institute of Optics and Fine Mechanics (China)
- 8551 0Q **Phase and spectrum control requirements of high intensity laser beam combining** [8551-31]
Y. Gao, Z. Cao, X. Yang, W. Feng, W. Ma, Shanghai Institute of Laser Plasma (China); B. Zhu, Shanghai Institute of Optics and Fine Mechanics (China); J. Zhu, Y. Dai, Shanghai Institute of Laser Plasma (China)

DIODE PUMPED LASERS

- 8551 0R **Fiber coupled high-power multi-mode diode pump lasers** [8551-32]
T. Wang, L. Jiang, Q. He, H. Hu, Oclaro (Shenzhen) Co. Ltd. (China); N. Zayer, Oclaro Technology Ltd. (United Kingdom); R. Baettig, Oclaro, Inc. (Switzerland); S. Cutillas, D. Lenarduzzi, E. Wolak, Oclaro, Inc. (United States); B. Valk, Oclaro, Inc. (Switzerland)

- 8551 OT **A novel external cavity with double volume Bragg gratings for rubidium laser pumping** [8551-35]
Z. Li, Institute of Electronics (China) and Graduate Univ. of the Chinese Academy of Sciences (China); R. Tan, Institute of Electronics (China); C. Xu, L. Li, Institute of Electronics (China) and Graduate Univ. of the Chinese Academy of Sciences (China)

NOVEL LASERS

- 8551 OU **High average power (11 W) eye-safe diamond Raman laser** [8551-36]
A. McKay, O. Kitzler, H. Liu, D. Fell, R. P. Mildren, Macquarie Univ. (Australia)

POSTER SESSION

- 8551 OY **Q-switched quasi-concentric laser resonator with line-shaped end-pumping profile: power-insensitive operating point and symmetrized TEM₀₀ output** [8551-6]
X. Fu, Q. Liu, M. Gong, Tsinghua Univ. (China)
- 8551 OZ **Modeling of distributed-side-pumped slab lasers: power scaling by adding slab units** [8551-19]
X. Fu, Q. Liu, M. Gong, Tsinghua Univ. (China)
- 8551 10 **Adaptive optics technology for Fourier telescope** [8551-22]
C. Lu, X. Gao, J. Tang, J. Wang, Beijing Institute of Tracking and Telecommunication Technology (China)
- 8551 12 **Treatment of numerical overflow in simulating error performance of free-space optical communication** [8551-41]
F. Li, Anhui Institute of Optics and Fine Mechanics (China) and Univ. of Science and Technology of China (China); Z. Hou, Y. Wu, Anhui Institute of Optics and Fine Mechanics (China)
- 8551 13 **Parameters optimization of the beam clean-up system based on stochastic parallel gradient descent method** [8551-42]
S. Wang, National Univ. of Defense Technology (China) and Taiyuan Satellite Launch Ctr. (China); J. Cui, Taiyuan Satellite Launch Ctr. (China); H. Ma, Y. Liang, Q. Yu, National Univ. of Defense Technology (China)
- 8551 14 **Numerical analysis of thermal effects in micro-evaporator cooling module** [8551-43]
S. Fan, P. Zhang, Y. Liang, Y. Zhang, Chongqing Normal Univ. (China)
- 8551 15 **Q-switched Yb-doped double cladding fiber laser with single wall carbon nanotube saturable absorber** [8551-44]
Z. Yu, Y. Song, C. Tian, J. Li, X. Zhang, Beijing Univ. of Technology (China); Y. Wang, The Hong Kong Polytechnic Univ. (China)
- 8551 17 **Temperature distribution of laser crystal in LD end-pumped Nd:YAG/LBO blue laser** [8551-49]
L. Zhang, Y. Zheng, S. Li, L. Jia, J. Kang, Shijiazhuang Univ. of Economics (China)

- 8551 18 **Oxygen partial pressure influence on the character of InGaZnO thin films grown by PLD** [8551-46]
Y. Lu, L. Wang, Beijing Univ. of Technology (China)
- 8551 19 **Passively Q-switched Nd:YCOB laser with a single-walled carbon nanotube saturable absorber** [8551-47]
J. Li, Y. Song, Z. Yu, C. Tian, Y. Li, Beijing Univ. of Technology (China); Y. Wang, The Hong Kong Polytechnic Univ. (Hong Kong, China)
- 8551 1A **Optical properties of single-walled carbon nanotubes and its applications in Q-switched lasers** [8551-48]
C. Tian, Y. Song, J. Li, Z. Yu, Beijing Univ. of Technology (China); Y. Wang, Academia Sinica (Taiwan); Y. Li, Beijing Univ. of Technology (China)
- 8551 1C **Numerical analysis of beam quality factor β on coherent combination of multiple laser beams** [8551-51]
Y. Tan, Institute of Optics and Electronics (China), The Key Lab. of Adaptive Optics (China), and Graduate School of the Chinese Academy of Sciences (China); X. Li, Institute of Optics and Electronics (China) and The Key Lab. of Adaptive Optics (China)
- 8551 1E **Narrow linewidth, wavelength-stable Er/Yb co-doped fiber MOPA source operating at 1547.8 nm** [8551-53]
H. Su, X. Li, Z. Dai, L. Xu, X. Li, Hebei Univ. (China)
- 8551 1F **High power diode-pumped composite YVO₄/Nd:YVO₄/YVO₄ actively Q-switched and mode-locked laser with ring resonator** [8551-55]
G. Huang, X. Xie, Z. Ou, C. Du, Shenzhen Univ. (China) and Shenzhen Key Lab. of Laser Engineering (China)
- 8551 1H **Microwave synthesis of Au nanoparticles as promising SERS substrates** [8551-58]
L. Wang, S. Feng, N. Liu, J. Lei, H. Lin, Fujian Normal Univ. (China); L. Sun, First Hospital of Fuzhou (China); R. Chen, Fujian Normal Univ. (China)
- 8551 1J **Characteristic research of the waveguide by nanosecond laser pulses on LiNbO₃** [8551-60]
Z. Zhou, C. Luo, Z. Fan, E. Quan, W. Zhu, L. Wang, Y. Yang, Southwest Univ. of Science and Technology (China)
- 8551 1K **An equivalent method to analyze the electrical effect induced by laser plasma** [8551-62]
Y. Ji, C. Wang, B. Bian, Nanjing Univ. of Science and Technology (China)

Author Index

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- 1 High Power Lasers
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- 2 Slab Lasers I
Jirong Yu, NASA Langley Research Center (United States)
- 3 Fiber Lasers
Robert F. Walter, Schafer Corporation (United States)
- 4 Slab Lasers II
Jinxue Wang, Ratheon Company (United States)

- 5 Laser Applications
Willy L. Bohn, BohnLaser Consult (Germany)
- 6 Ultrafast Lasers
Han Zhang, Hunan University (China)
- 7 Diode Pumped Lasers
Willy L. Bohn, BohnLaser Consult (Germany)
- 8 Novel Lasers
Han Zhang, Hunan University (China)